# Growth, Structure and Piezoelectric Properties of Ln<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub> (Ln= La, Nd) Single Crystals

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Piezoelectric La<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub> (LGS) and Nd<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub> (NGS) single crystals with a Ca<sub>3</sub>Ga<sub>2</sub>Ge<sub>4</sub>O<sub>14</sub>-type structure were grown by the Czochralski technique and their electric properties were investigated. The size of the grown crystals was 18-25 mm in diameter and 72-110 mm in length. The crystal structure of both crystals has been refined from the single crystal X-ray diffraction data. Except for the lanthanoide site, the cation distribution on each site in NGS is same as that of LGS. The dielectric, piezoelectric and elastic compliance constants of the LGS and NGS crystals were evaluated. The independent piezoelectric moduli  $d_{11}$  and  $d_{14}$  of the NGS crystal were approximately half that of the LGS one. The substitution of the lanthanoide site in the LGS-type crystals significantly affected the piezoelectric properties.

Key words: rare-earth element, langasite, crystal growth, crystal structure, piezoelectric properties

## 1. INTRODUCTION

La<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub> (langasite, LGS) crystals [1] have been promising piezoelectric materials for the fabrication of filters with large passband widths and oscillators with large shifts or high frequency stabilities [2,3]. Actually, surface acoustic wave (SAW) filters made of LGS wafers have already been mass-produced for use in a wideband-code division multiple access (W-CDMA) station. Very recently, LGS-type crystals also have attracted the attention as pressure sensor materials usable at high temperature, because LGS shows no phase transitions up to its melting temperature. However, there are few reports about the physical properties at high temperature in LGS. Furthermore, since there are few data about the piezoelectric properties of other LGS-type crystals at room temperature, it has not been clarified that LGS is the most appropriate material for all LGS-type crystals. Under this situation, we have investigated the substitution effect of La<sup>3+</sup> in LGS on the growth, structure and piezoelectric properties. We have been determining all the material constants of lanthanoide gallium silicates (LGS and Nd3Ga5SiO14; NGS) and comparing them. Although the authors in ref.[4] have already reported one piezoelectric constant, other material constants have not yet been determined. The obtained data are useful for developing newer candidates for pressure sensor devices that work at high temperature.

In this paper, we report the growth of LGS and NGS crystals by the Czochralski (Cz) technique, and their detailed crystal structure and material constants.

### 2. CRYSTAL GROWTH

Single crystals were grown by the conventional

RF-heating Cz technique using an iridium crucible (50 mm diameter and height). The starting materials were prepared by mixing 99.99% pure La(Nd)<sub>2</sub>O<sub>3</sub>, Ga<sub>2</sub>O<sub>3</sub> and SiO<sub>2</sub> powders in a stoichiometric ratio. The powders were mixed in air, and then calcined at 1000°C for 2 h. They were then heated at 1350 °C for 5 h. The L(N)GS powders were uniaxially pressed in a disk form with a 48 mm diameter and ~ 30mm thickness, and were charged into the crucible. The growth atmosphere was an 1vol%O<sub>2</sub>+Ar gas flow of 10<sup>-3</sup> m<sup>3</sup>/min. The pulling rate and the rotation rate were 1.0~ 1.5 mm/h and 10 rpm, respectively. The observation of bubbles and inclusions in the crystals was performed using an optical microscope. The density of the grown crystals was measured by the Archimedes method using distilled water at room temperature.

We have successfully obtained L(N)GS single crystals pulled in the <001> direction by the Cz technique. Since no growth instability such as spiral symptom appeared during the growth, the uniform diameter of the grown crystals was easily controlled. The grown LGS crystal had a 25 mm diameter and 110 mm length and the NGS had an 18 mm diameter and 72 mm length. Both crystals showed a smooth surface, and were transparent with a orange color for LGS and deep purple color for NGS. No cracks and inclusions were found inside the grown crystals. All peaks of the powder X-ray diffraction patterns of the boules were identified to be those of the LGS-type structure. The measured density (Dm) is 5.742(3) g/cm<sup>3</sup> and 6.008(5) g/cm<sup>3</sup> for the LGS and NGS crystals, respectively. (cf. Table 4)

## 3. STRUCTURE ANALYSIS

The L(N)GS crystals have the  $Ca_3Ga_2Ge_4O_{14}$ -type structure (space group P321) [1]. There are four kinds of

cation sites in the structure with the chemical formula  $A_3BC_3D_2O_{14}$ . A part of the crystal structure is schematically shown in Figure 1. The notations *A* and *B* represent a decahedral (twisted Thomson cube) site coordinated by eight oxygens, and an octahedral site coordinated by six oxygens, respectively. Moreover, *C* and *D* represent tetrahedral sites coordinated by four oxygens, the size of the *D* site is smaller than that of the *C* site. In the Ca<sub>3</sub>Ga<sub>2</sub>Ge<sub>4</sub>O<sub>14</sub> crystal, Ca<sup>2+</sup> occupies the *A* site, Ga<sup>3+</sup> occupies the *B* and one of three *C* and *D* sites.

Each single crystal, cut from the grown crystal, was ground into a spherical shape and used for the present single crystal structure analysis. X-ray intensity data were collected with MoKa radiation ( $\lambda$ =0.71069 Å) on a Rigaku AFC-6 four-circle diffractometer using a pyrolytic graphite monochromater in the incident beam path. The  $\omega$ -2 $\theta$  scan technique was used to collect the integrated intensity data up to  $2\theta = 90^{\circ}$  with a scan speed of  $\theta = 4$  °/min. From the total of 1821-1875 reflections, measured within the ranges of  $16 \le h \le 0$ ,  $0 \le k \le 16$  and  $0 \le l \le 10$ , 1414-1484 reflections with  $F \ge 3\sigma(F)$  were used for the refinement. The cell dimensions were determined by a least squares calculation of twenty  $2\theta$  values between  $20^{\circ} < 2\theta < 30^{\circ}$ . After corrections for the Lorentz, polarization and absorption effects, the anisotropic refinement with the corrections for an isotropic extinction (TYPE II) [5] were simultaneously carried out using the full matrix least-squares program LSGC [6]. The atomic scattering factors [7] for La(Nd), Ga, Si and O together with anomalous scattering factors were used so as to minimize the residuals of the function  $\sum w_i (|F_o| - k|F_c|)^2$  where  $w_i = 1/\sigma^2(F)$  and k is the scale factor. The final R and  $R_w$  values for the



**Fig.1** Schematic coordination polyhedra of oxygen atoms around cationic atoms in  $La_3Ga_5SiO_{14}$ -type structure. Open circle (()), coarse dot circle (()), fine dot circle (()), hatched circle () and solid circle (), represent oxygen atoms, the eight-(A), six-(B), four-(C) and smaller four-coordination (D) sites, respectively.

refinement with anisotropic temperature factors were 0.037-0.039 and 0.040-0.041, respectively. Detailed information of the data collection and refinement are summarized in Table I. The positional parameters, isotropic thermal parameters and selected interatomic distances are listed in Tables 2 and 3 for the LGS and NGS crystals, respectively.

For the LGS and NGS crystals, the distributions of Si and Ga were analyzed by common site-multiplicity refinement. For the first time, the distribution of Si within the octahedral (B;Ga1) and two tetrahedral

	La <sub>3</sub> Ga <sub>5</sub> SiO <sub>14</sub>	Nd <sub>3</sub> Ga <sub>5</sub> SiO <sub>14</sub>
Color	orange	purple
Diameter of specimen (mm)	0.115	0.146
Crystal system	Trigo	onal
Space group	P321 (N	lo.150)
Lattice parameters	a = 8.161(1) Å	a = 8.062(1) Å
Lattice parameters	c = 5.094(1) Å	c = 5.062(2) Å
Volume (Å <sup>3</sup> )	293.8	284.93
Formula weight	1017.41	1033.41
Calculated density (g/cm <sup>3</sup> )	5.750	6.019
Radiation	Μο Κα (λ =	0.71069 Å)
Monochromator	Graphit	e (002)
μ (Mo Kα) (mm <sup>-1</sup> )	22.04	25.26
Maximum 20 (°)	90	0
No. of reflections measured	1875	1821
No. of independent reflections	1619	1571
No. of used reflections $[F^2 ? 3\sigma(F^2)]$	1414	1484
R	0.039	0.037
R <sub>w</sub>	0.040	0.041
Goodness of fit	1.111	1.326

Table 1 Crystal Data and Intensity Collection for Ln<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub> (Ln=La, Nd)

(a)											_			
5	Site		Atc	m		x		у			z			B
La	3	е	La		0.4187	4(6)	0		0				0.	669(8)
Gal	1	а	Ga		0		0		0				0.	87(3)
Ga2	3	f	Ga		0.7655	(2)	0		1.	/2			0.	68(2)
Ga3	2	d	Ga+S	Si	1/3		2/3		0	.4678(	3)		0.	60(3)
01	2	d	0		1/3		2/3		0	.805(2	)		1.	22(13)
02	6	g	0		0.4649	(8)	0.31	17(8)	0	.682(1	)		1.	50(9)
_03_	6	<u>g</u>	0		0.2220	(8)	0.08	302(8)	0	.2376(	9)		1.	54(9)
(b)														
		Ga	al oct	ahec	Iron		Ga2	tetrahe	dron			Ga3 t	etrah	edron
Ga1	-	O3	×	6	1.997(6)	Ga2 <sup>ii</sup> -	$O2^{vii}$	×2	1.900(6)	Ga3 <sup>i</sup>	-	O1 <sup>iv</sup>	×1	1.715(9)
O3	-	O3 <sup>3</sup>	× ×	6	2.752(9)	-	O3 <sup>x</sup>	×2	1.804(5)		-	O2 <sup>vii</sup>	×3	1.743(6)
	-	03	<sup>xi</sup> ×	3	2.673(7)	(Ga2-	-O) <sub>av</sub>		1.852	(0	Ja3-	-O) <sub>av</sub>		1.736
	-	O3'	<sup>uii</sup> ×	3	3.142 (8)	O2 <sup>vii</sup> -	$O2^{ix}$	$\times 1$	2.854(8)	O1 <sup>iv</sup>	-	O2 <sup>vii</sup>	×3	2.934(9)
1	(0-(	D) <sub>av</sub>			2.830	-	O3 <sup>xiii</sup>	×2	2.982(9)	O2 <sup>vii</sup>	-	O2 <sup>viii</sup>	×3	2.712(9)
						O2 <sup>ix</sup> -	O3 <sup>x</sup>	×2	2.874(9)	. (	0-0	D) <sub>av</sub>		2.823
						O3* -	O3 <sup>xiii</sup>	×1	3.341(7)					
						(0-0	D) <sub>av</sub>		2.985					
							Lap	olyhed	iron					
La	· _	O1 <sup>i</sup>	iii ×2	2	2.642(3)	O1 <sup>iii</sup> -	O2 <sup>viii</sup>	×2	3.611(6)	O2 <sup>v</sup>	-	O3	×2	2.986(8)
	-	$O2^i$	iv ×:	2	2.504(6)		O2 <sup>v</sup>	×4	3.046(10)		-	$O2^{vi}$	×2	2.712(9)
	-	02	×.	2	2.876(6)		03	×2	3.160(7)		-	O3 <sup>xi</sup>	×2	3.428(8)
	-	03	×	2	2.350(5)					$O2^{vi}$	-	$O2^{viii}$	$\times 1$	3.893(8)
(	La-(	O) <sub>av</sub>			2.593					03	-	O3 <sup>xi</sup>	$\times 1$	2.673(7)
										(	0-0	))		3.519

Table 2 (a) Atomic parameters and (b) selected interatomic distances [Å] of  $La_3Ga_5SiO_{14}$  with estimated standard deviations in parentheses.

Table 3 (a) Atomic parameters and (b) selected interatomic distances [Å] of  $Nd_3Ga_5SiO_{14}$  with estimated standard deviations in parentheses.

_(a)													
S	ite		Atom		x		у		2	2			B
Nd	30	e N	d	0.4179	6(5)	0		0				0.	690(8)
Ga1	14	a G	a	0		0		0				0.	83(2)
Ga2	3j	r G	a	0.7647	(1)	0		1/	/2			0.	73(2)
Ga3	20	d G	a+Si	1/3		2/3		0	.4651(3	3)		0.	62(3)
01	20	<i>d</i> 0		1/3		2/3		0.	.803(2)			1.	24(13)
02	68	3 O		0.4663	(8)	0.31	71(8)	0.	.689(1)	ł		1.	72(10)
_03	6	<u>z</u> 0		0.2230	(8)	0.07	756(8)	0	2403(9	<del>)</del> )		1.	45(9)
_(b)													
		Ga1	octahe	dron		Ga2	tetrahe	dron			Ga3 (	tetrah	edron
Ga1	-	03	×6	1.997(6)	Ga2 <sup>ii</sup> -	O2 <sup>vii</sup>	×2	1.895(7)	Ga3 <sup>i</sup>	-	O1 <sup>iv</sup>	$\times 1$	1.711(9)
O3	-	O3 <sup>x</sup>	×6	2.743(9)	-	O3 <sup>x</sup>	×2	1.808(5)		-	O2 <sup>vii</sup>	×3	1.737(7)
	-	03 <sup>xi</sup>	×3	2.652(7)	(Ga2-	-O) <sub>av</sub>		1.852	(G	a3-	O) <sub>av</sub>		1.731
	-	O3 <sup>xii</sup>	×3	3.187(8)	O2 <sup>vii</sup> -	O2 <sup>ix</sup>	×1	2.827(8)	01 <sup>iv</sup>	-	O2 <sup>vii</sup>	×3	2.934(10)
(	0-0	)) <sub>av</sub>		2.830		O3 <sup>xiii</sup>	×2	2.996(9)	O2 <sup>vii</sup>	-	O2 <sup>viii</sup>	×3	2.690(9)
					O2 <sup>ix</sup> -	O3 <sup>x</sup>	×2	2.871(9)	((	<b>)-</b> (	D) <sub>av</sub>		2.812
					O3 <sup>x</sup> -	O3 <sup>xiii</sup>	$\times 1$	3.339(7)					
					(0-0	O) <sub>av</sub>		2.983					
Nd polyhedron													
Nd	-	$O1^{iii}$	×2	2.617(3)	O1 <sup>iii</sup> -	O2 <sup>viii</sup>	×2	3.528(6)	O2 <sup>v</sup>	-	O3	$\times 2$	2.937(8)
	-	O2 <sup>iv</sup>	×2	2.433(6)		O2 <sup>v</sup>	×4	3.005(10)		-	$O2^{vi}$	×2	2.690(10)
	-	O2 <sup>v</sup>	$\times 2$	2.859(7)		O3	×2	3.119(7)		-	O3 <sup>xi</sup>	×2	3.409(8)
	-	O3	×2	2.230(7)					$O2^{vi}$	-	$O2^{viii}$	$\times 1$	3.778(9)
()	Nd-	O) <sub>av</sub>		2.535					O3	-	O3 <sup>xi</sup>	$\times 1$	2.673(7)
-									((	0-0	D) <sub>av</sub>		3.114

(C;Ga2 and D;Ga3) sites was examined. The obtained s tructural parameters clearly indicated that the Si atoms occupy all the smaller tetrahedral (D) sites within the estimated error. Therefore, it was suggested that the Ga atoms occupy another tetrahedral (C) site. Moreover, the decahedral (A) and octahedral(B) sites are fully occupied

by La(Nd) and Ga, respectively. The chemical composition determined from the X-ray diffraction data agreed well with that determined from the chemical analysis within the estimated error. Therefore, the chemical formula of La(Nd)<sub>3</sub>Ga<sub>2</sub>Ge<sub>4</sub>O<sub>14</sub> can be represented as  $(La(Nd)_3)^{3e}(Ga_1)^{1a}(Ga_3)^{3f}(Ga_1Si_1)^{2d}O_{14}$ 

	La <sub>3</sub> Ga <sub>5</sub> SiO <sub>14</sub>	Nd <sub>3</sub> Ga <sub>5</sub> SiO <sub>14</sub>
D <sub>m</sub>	5.742	6.008
<i>k</i> <sub>12</sub>	14.75	9.68
k <sub>25</sub>	8.88	2.85
k <sub>26</sub>	13.82	12.13
$\varepsilon_{11}^T/\varepsilon_0$	$19.88 \pm 0.6$	$20.22 \pm 0.4$
$\varepsilon_{33}^{T}/\varepsilon_{0}$	$50.83 \pm 0.1$	$63.36 \pm 0.1$
<i>d</i> <sub>11</sub>	5.95	4.05
<i>d</i> <sub>14</sub>	-5.38	-2.07
$s^{E}_{11}$	9.19	9.78
s <sup>E</sup> <sub>12</sub>	-3.95	-3.69
s <sup>E</sup> <sub>13</sub>	-1.78	-2.00
s <sup>E</sup> <sub>14</sub>	-3.40	-3.43
s <sup>E</sup> 33	5.42	6.34
s <sup>E</sup> 44	20.3	19.1
s <sup>E</sup> 66	26.28	26.93

Table 4 Properties of Ln<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub> (Ln=La, Nd)

 $D_{\rm m}$  : Experimental density [g/cm<sup>3</sup>]

: Electromechanical coupling factor

 $k_{ij}$ : Electromechanica  $\varepsilon_{ij}$  $\varepsilon_{ij}^{T} \varepsilon_{0}$ : Relative dielectric constant [PC/I

 $d_{ij}$  : Piezoelectric constant [pC/N]  $s^{E}_{11}$  : Elastic compliance constant [×10<sup>12</sup> m<sup>2</sup>/N]

with the Wyckoff-site notation superscripted.

As can be seen in Tables 2 and 3, for the LGS and NGS crystals, the average *B*-O distance (1.997 Å) is closer to the estimated  $Ga^{VI}$ -O distance (2.000 Å) [8]. This result supports the full occupation of Ga atoms at the B site in both crystals. The mean C-O distance (1.852 Å) is longer than the mean D-O distance (1.731-1.736 Å). This result suggests that the Si atoms occupy the D site. The shape of the Ga3 tetrahedron appears to be more distorted. The average B, C and D-O distances in LGS are the same as the corresponding ones in NGS, whereas the average A-O one (2.593 Å) of LGS is apparently longer than that (2.535 Å) of NGS. This decrease is due to the ionic size (1.109 Å) of Nd<sup>3+</sup>  $(1.160 \text{ Å for } \text{La}^{3+})$  [8]. Moreover, there is very small difference in the average O-O distance of the octahedral and two tetrahedral sites. These results show that the substitution of La<sup>3+</sup> with Nd<sup>3+</sup> only affects the size of the decahedral site (A-site).

## 4. EVALUATION OF MATERIAL CONSTANTS

LaCOB crystals belong to the torigonal system P321. Independent material constants in point group 32 consist of two dielectric, two piezoelectric and six elastic compliance constants ( $\varepsilon_{ii}$ ,  $d_{ij}$  and  $s_{ij}$ , respectively). The total number of constants that should be obtained is ten. The material constants were determined using an impedance/gain phase analyzer (HP 4194A: Agilent) as reported in refs.[9,10]. The electromechanical coupling factor  $k_{ii}$  and the piezoelectric modulus were evaluated by measuring the mechanical series resonance frequency  $f_{\rm s}$  and parallel resonance frequency  $f_{\rm p}$  of equivalent resonators. The equivalent resonators were fabricated in the form of bars, plates and rotating cuts according to each vibration mode such as the thickness-extensional mode. The dielectric constants  $\varepsilon_{ii}$  were determined by measuring the capacitances of the resonators by taking the parasitic capacitance into account.

All the evaluated material constants of the LGS and NGS crystals are shown in Table 4. All the constants of LGS and the piezoelectric constant  $d_{11}$  of NGS agreed with those reported in refs.[11] and [4], respectively. About the piezoelectric constants  $d_{11}$  and  $d_{14}$ , we found the dependence of the piezoelectric constant on the rare earth elements occupying the decahedral site in  $Ln_3Ga_5SiO_{14}$  (Ln = La and Nd) crystals. In ref.[4], it is reported that the absolute piezoelectric modulus  $|d_{11}|$ decreases with the decreasing ionic radius of a rare-earth element occupying the A-site in  $Ln_3Ga_5SiO_{14}$  (Ln = La, Pr and Nd). Moreover, we found higher decreases in the  $d_{14}$  value. In the crystal structure data, we determined the decrease in the size of the decahedral site (A-site) by the substitution of La<sup>3+</sup> with Nd<sup>3+</sup>. Hence, the substitution of the A-site in the LGS-type crystal significantly affected the piezoelectric properties. This observation will give a hint to developing new LGS-type crystals with superior piezoelectric properties.

#### 5. SUMMARY

Piezoelectric LGS and NGS single crystals were grown by the Czochralski technique. The results of a single-crystal X-ray structure analysis indicated that the cation distribution on each site in NGS is the same as that of LGS. Using the grown crystals, all material constants of the LGS and NGS crystals were evaluated. The determined piezoelectric constants decreased with the decreasing ionic radius of the rare earth element occupying the A-site in Ln<sub>3</sub>Ga<sub>5</sub>SiO<sub>14</sub>.

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